

prep*FAST* S

## **Automated Introduction Semiconductor Chemicals**

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Fluoronetic prep*FAST* S Ultraclean Sample Introduction System

**Elemental Scientific** 

ICP | ICPMS

## prepFASTS

### Automated Sample Preparation and Introduction System for Semiconductor Applications

The prep*FAST* S has revolutionized the way ultrapure semiconductor grade chemicals are analyzed with ICPMS detection. The prep*FAST* S utilizes syringe-driven flows of UPW, semiconductor grade acids, and standard solution to automate both sample dilutions and standard curve generation. It eliminates manual handling of samples to deliver sub-ppt detection limit capabilities.

#### prepFAST S Autocalibration

The prep*FAST* S automatically prepares calibration curves for over 40 elements controlled in semiconductor manufacturing processes. Calibrations are generated by automatically diluting an enclosed multielement stock standard. Automation with the high-purity prep*FAST* S achieves low to sub-ppt calibrations.



## prepFASTS

### High Purity Automation with PPT/PPQ Results

#### Automation

- · Automatic external and MSA calibrations
- Automated sample sensing
  - Accounts for viscosity and automatically adjusts timing
  - Detects and injects the sample and triggers the ICPMS
- Automated syringe-driven sample introduction
  - Sample loading
  - Sample preparation
  - Inline dilution
  - Acid addition

#### Ultraclean

- Ultaclean sample preparation
- Integrated ultraclean sample environment
  - Includes ultraclean fluoronetic autosampler and air shower
  - Options include:
    - ULPA (Ultrapure air) filter
    - Sample racks for PFA containers (<1 mL to 500 mL)
- Continuously-flowing high purity UPW rinse (user-supplied UPW)
- UPW polishing columns for low background

#### **PPT/PPQ Results**

- · Capability to analyze all semiconductor grade chemicals
- PPT/PPQ detection limits for all semiconductor elements

prep <i>FAST</i> S System						
System	Integrated Mobile Autosampler & Enclosure	Ultraclean Air Shower	Integrated FAST valve modules	PFA Nebulizer with Integrated Capillary	PFA Sample Probes	Syringe Pump S500V2
prep <i>F</i> AST S	$\checkmark$	$\checkmark$	$\checkmark$	$\checkmark$	$\checkmark$	$\checkmark$

### **Pure Automation**



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### **Pure Automation**

### prepFAST S Inline Dilution of Semiconductor-grade Chemicals



The prep*FAST* S allows dilution by volume or weight for all semiconductor-grade chemicals. Metals are quantified using automated inline MSA or external calibration. Automated direct analysis of concentrated chemicals eliminates sample contamination caused by manual dilution into a secondary container.

#### Examples of Semiconductor Chemicals Analyzed at the PPT Level with prepFAST S

Acids	98% H <sub>2</sub> SO <sub>4</sub>	89% H <sub>3</sub> PO <sub>4</sub>	70% HNO <sub>3</sub>	49% HF	35% HCI	30% H <sub>2</sub> O <sub>2</sub>
Bases	$22\% \text{ NH}_4 \text{OH}$	2.38% TMAH	25%TMAH	KOH		
Organics	IPA	PGMEA/PGME	Photoresist	NMP	Butyl Acetate	Cyclohexanone

This table contains only a partial list of chemicals which can be analyzed using prepFAST S.

Diagram showing 10x inline dilution of concentrated  $H_2SO_4$  with prep*FAST* S.

# **Detection Limits**

Example of Detection Limits in Non-Cleanroom Environment							
Element	DL (PPT)	Element	DL (PPT)				
<sup>7</sup> Li	0.02	<sup>72</sup> Ge	0.04				
<sup>9</sup> Be	0.007	<sup>75</sup> As	0.2				
<sup>11</sup> B	0.9	<sup>85</sup> Rb	0.008				
<sup>23</sup> Na	0.07	<sup>88</sup> Sr	0.008				
<sup>24</sup> Mg	0.01	<sup>90</sup> Zr	0.004				
<sup>27</sup> AI	0.03	<sup>93</sup> Nb	0.002				
<sup>39</sup> K	0.06	<sup>95</sup> Mo	0.5				
<sup>40</sup> Ca	0.4	<sup>111</sup> Cd	0.07				
<sup>48</sup> Ti	0.02	<sup>115</sup> In	0.004				
<sup>51</sup> V	0.1	<sup>118</sup> Sn	0.05				
<sup>52</sup> Cr	0.1	<sup>121</sup> Sb	0.05				
<sup>55</sup> Mn	0.009	<sup>137</sup> Ba	0.04				
<sup>56</sup> Fe	0.04	<sup>178</sup> Hf	0.003				
<sup>58</sup> Ni	0.01	<sup>181</sup> Ta	0.01				
<sup>59</sup> Co	0.007	<sup>182</sup> W	0.01				
<sup>60</sup> Ni	0.01	<sup>205</sup> TI	0.002				
<sup>63</sup> Cu	0.03	<sup>208</sup> Pb	0.005				
<sup>64</sup> Zn	0.04	<sup>232</sup> Th	0.000				
<sup>71</sup> Ga	0.002	<sup>238</sup> U	0.003				

# Autocalibration

### UPW Autocalibration for <sup>40</sup>Ca







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